

IN THE CLAIMS:

Please correct the listed claims, as follows. For the Examiner's convenience, all the claims currently pending in this application, including those not currently being amended, have been reproduced below.

1-13. (Cancelled)

14. (Previously Presented) A method for manufacturing a substrate having a fine line on a substrate face, said method comprising:

a fine-line forming step of forming the fine line on the substrate face, wherein a narrow-width portion is provided at an end portion of the fine line in a longitudinal direction, and the fine line is formed so that a width of the narrow-width portion in a parallel direction to the substrate face is smaller than a width of a portion adjacent to the narrow-width portion, and in a section of the fine line cut in the direction of a normal line on the face forming the fine line on the substrate, the section comprises a part which is away from the substrate-side-end of the section, and a length of a part of the section in the parallel direction to the substrate face is longer than a length of the substrate-side-end of the section in the parallel direction to the substrate face, said fine-line forming step comprising:

(i) a step of providing a photosensitive material onto the substrate;

(ii) a step of projecting light from above the substrate onto a predetermined region on the photosensitive material; and

(iii) a developing step after said step of projecting light.

15-18. (Cancelled)